

# **Potential-Induced Degradation within Perovskite Solar Cells**

Robbe Breugelmans



- Potential-Induced Degradation
- Current state of the art in literature
- PID experiment and results
- Conclusion and outlook



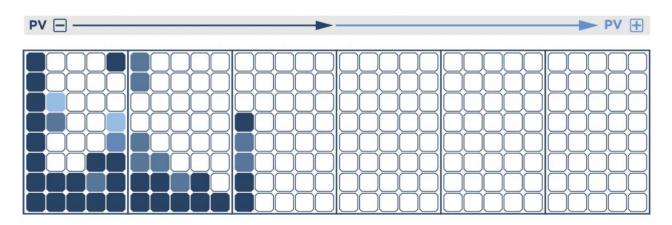


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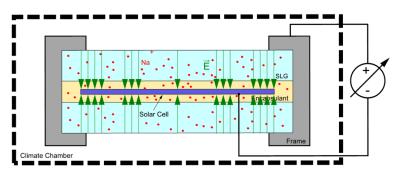


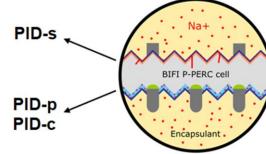


# Potential-Induced Degradation (Silicon)















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## Current state of the art in literature (perovskite)

- 3 publications available

Reference	Year	Perovskite structure	Stress duration	Voltage difference	Condition	Efficiency loss
[3]	2019	n-i-p	18 hours	1000 V	60°C / <60% RH	95%
[4]	2021	n-i-p, p-i-n	18 hours	1000 V	60°C / <60% RH	65.3% / 72%
[5]	2021	p-i-n	5000 hours	1000 V / 500 V	25°C / 20% RH	±90%

- Recovery investigated
- Sensitive to moisture, light, and thermal stress
- Challenging to isolate the PID mechanism





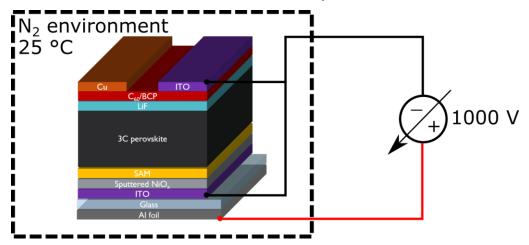
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## PID experiment and results

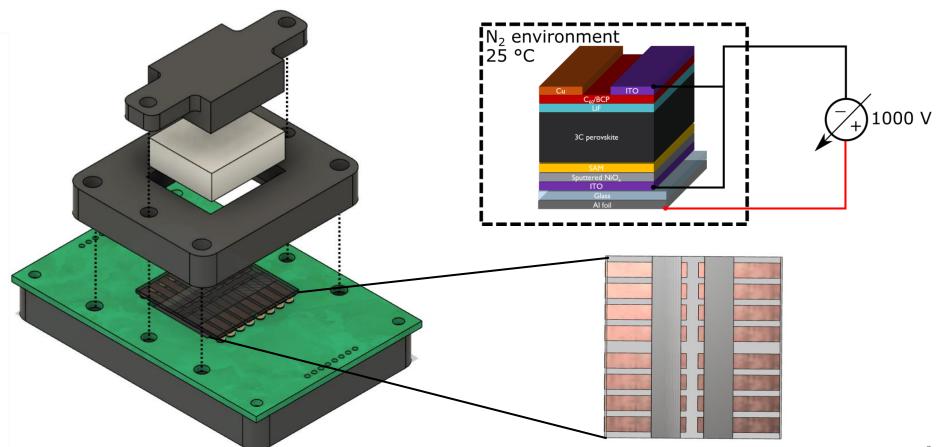
- Retrieving accurate insights in PID mechanism
- Controlled N<sub>2</sub> environment at ambient temperature
  - Exclusion moisture influence
  - Exclusion thermal influence
- Comparison PID sensitivity Cu-and ITO-contacted samples
- 3C p-i-n perovskite
  - $Cs_{0.05}FA_{0.85}MA_{0.1}PbI_{2.9}Br_{0.1}$





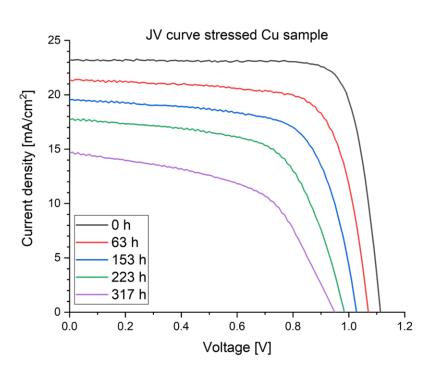


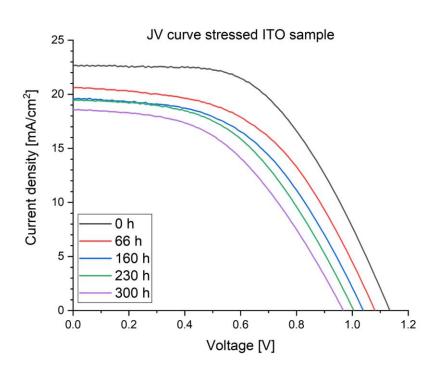
# PID experiment and results: Setup



# PID experiment and results: JV

- 1000V potential difference, 25°C, ±300 hours



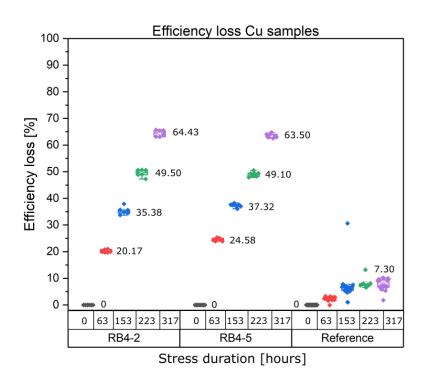


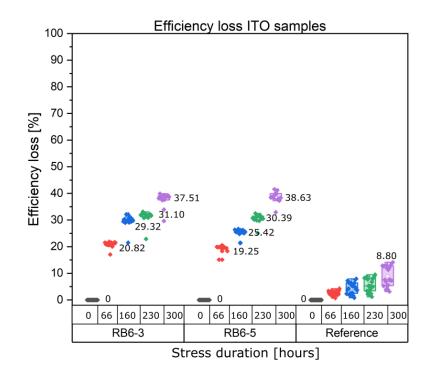




# PID experiment and results

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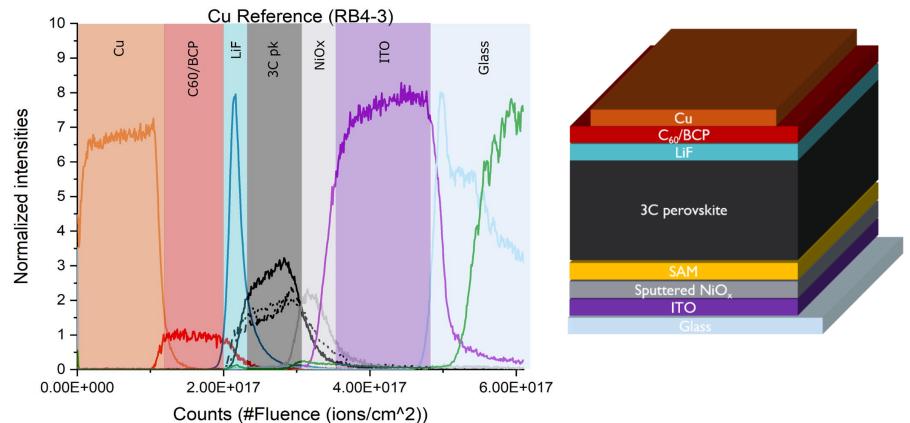




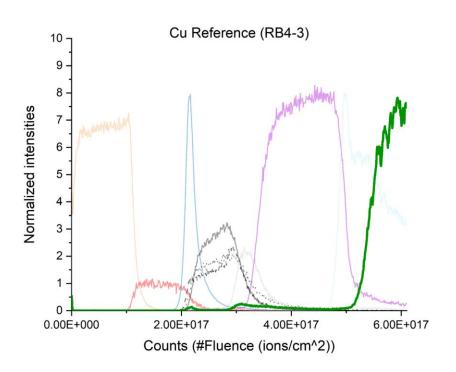


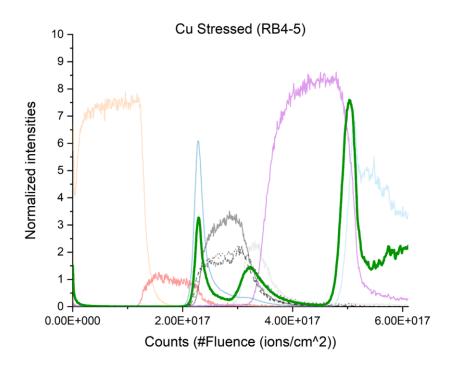


# PID experiment and results: ToF-SIMS



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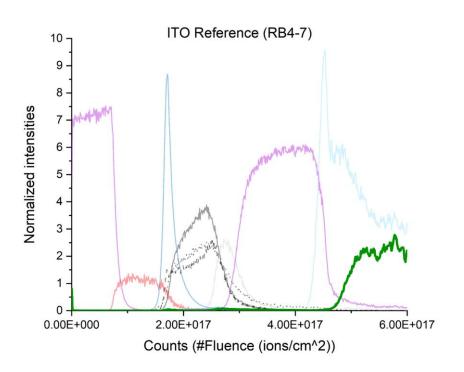


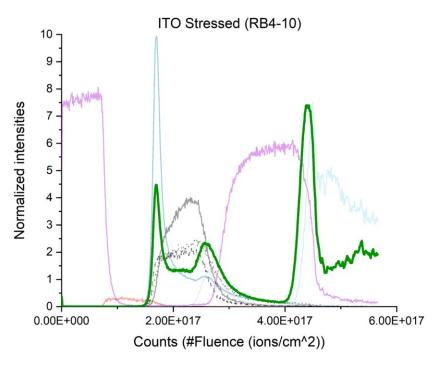






# PID experiment and results: ToF-SIMS









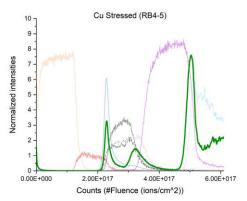
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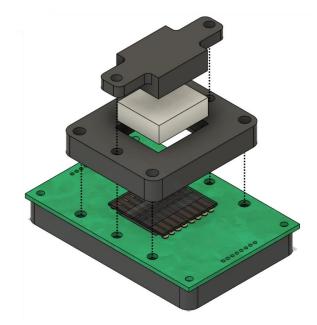


## Conclusion and outlook

- Influence of H<sub>2</sub>O excluded by N<sub>2</sub> environment
- Na<sup>+</sup> migration is the main cause of PID
- Cu samples more PID-prone than ITO
  - Twofold effect: Metal-induced degradation + PID?



- Further comparisons
  - 2C vs 3C
  - 2D vs 3D
  - Dependencies of other layers
- Voltage and temperature dependency
- Influence on module level
- Recovery
- Prevention









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